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IN THE CLAIMS:

The claims remain as follows:

Claim 1 (Currently Amended): An organic semiconductor device comprising:

a pair of opposing electrodes;

a carrier mobility organic semiconductor layer formed between the pair of opposing

electrodes; and

a buffer layer inserted between at least one of the pair of electrodes and the organic

semiconductor layer in contact therewith and has a work function or an ionization potential

between a value of a work function of the electrode in contact and a value of an ionization

potential of the organic semiconductor layer,

wherein the pair of electrodes is a source electrode and a drain electrode, the organic

semiconductor layer is laminated so as to form a channel between the source electrode and the

drain electrode, and a gate electrode is disposed so as to apply an electric field on the organic

semiconductor layer disposed between the source electrode and the drain electrode.

Claim 2 (Original): An organic semiconductor device as set forth in claim 1, wherein the

organic semiconductor layer is made of a P-type semiconductor.

Claim 3 (Original): An organic semiconductor device as set forth in claim 1, wherein the

buffer layer is made of a metal, a metal oxide or an organic compound.

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Claim 4 (Original): An organic semiconductor device as set forth in claim 1, wherein the

buffer layer has a film thickness of 5000 angstroms or less.

Claim 5 (Original): An organic semiconductor device as set forth in claim 4, wherein the

buffer layer has a film thickness of 1000 angstroms or less.

Claim 6 (Currently Amended): An organic semiconductor device as set forth in claim 1,

wherein the buffer layer is formed discretely in island structure.

Claim 7 (Canceled).

Claim 8 (Currently Amended): An organic semiconductor device as set forth in claim 1

[[7]], wherein a gate insulating film that electrically isolates the gate electrode from the source

electrode and the drain electrode is provided.

Claim 9 (Currently Amended): An organic semiconductor device as set forth in claim 1

[[7]], wherein both of the source electrode and the drain electrode are disposed on a surface on

one side of the organic semiconductor layer.

Claim 10 (Currently Amended): An organic semiconductor device as set forth in claim 1

[[7]], wherein each of the source electrode and the drain electrode is disposed on one of both

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sides of the organic semiconductor layer with the organic semiconductor layer interposed

therebetween.

Claim 11 (Currently Amended): An organic semiconductor device as set forth in claim 1,

comprising:

a pair of opposing electrodes;

a carrier mobility organic semiconductor layer formed between the pair of opposing

electrodes; and

a buffer layer inserted between at least one of the pair of electrodes and the organic

semiconductor layer in contact therewith and has a work function or an ionization potential

between a value of a work function of the electrode in contact and a value of an ionization

potential of the organic semiconductor layer,

wherein the pair of electrodes is a source electrode and a drain electrode, the organic

semiconductor layer is laminated in a film thickness direction so that the organic semiconductor

layer is interposed between the source electrode and the drain electrode, and a gate electrode

buried in the organic semiconductor layer is provided.

Claim 12 (Withdrawn): An organic semiconductor device as set forth in claim 11,

wherein the gate electrode buried in the organic semiconductor layer is formed in lattice, in comb

or in slit.